AMENDMENTS TO THE SPECIFICATION

Please amend paragraph 0024 starting at page 9, line 3 as follows:

[0024] The invention, in part, pertains to a fabricating method of a liquid crystal display device

that includes forming a thin film transistor on a first substrate substrate, forming a passivation

layer covering the thin film transistor and including an organic material, forming an inorganic

insulating layer on the passivation layer, forming a seal pattern surrounding the thin film

transistor, and attaching a second substrate to the first substrate such that the seal pattern contacts

the inorganic insulating layer and the second substrate.